UNITED STATES SECURITIES AND EXCHANGE COMMISSION

Washington, D.C. 20549

FORM 8-K

CURRENT REPORT

PURSUANT TO SECTIONS 13 OR 15(d) OF THE SECURITIES EXCHANGE ACT OF 1934

Date of report (Date of earliest event reported) May 23, 2012

ENTEGRIS, INC.

(Exact name of registrant as Specified in its Charter)

Delaware (State or Other Jurisdiction of Incorporation or Organization)

001-32598

(Commission File Number)

129 Concord Road, Billerica, MA (Address of principal executive offices) 41-1941551 (I.R.S. Employer Identification No.)

> 01821 (Zip Code)

(978) 436-6500

(Registrant's telephone number, including area code)

N/A

(Former Name or Former Address, if Changed Since Last Report)

Check the appropriate box below if the Form 8-K filing is intended to simultaneously satisfy the filing obligation of the registrant under any of the following provisions:

□ Written communications pursuant to Rule 425 under the Securities Act (17 CFR 230.425)

□ Soliciting material pursuant to Rule 14a-12 under the Exchange Act (17 CFR 240.14a-12)

Pre-commencement communications pursuant to Rule 14d-2(b) under the Exchange Act (17 CFR 240.14d-2(b))

Pre-commencement communications pursuant to Rule 13e-4(c) under the Exchange Act (17 CFR 240.13e-4(c))

Item 7.01 Regulation FD Disclosure.

On May 23, 2012, Entegris, Inc. (the "Company") participated in an Analysts Day at the NASDAQ. Pursuant to Item 7.01 "Regulation FD Disclosure" of Form 8-K, the Company is furnishing a series of slides referenced in the Company's remarks at this conference. Presentation slides and an audio replay of the remarks will be posted on the Company's website for a period of 30 days.

In accordance with General Instructions B.2 of Form 8-K, the information in this Item 7.01 shall not be deemed "filed" for purposes of Section 18 of the Securities Exchange Act of 1934, as amended (the "Exchange Act"), or otherwise subject to the liabilities of that section, nor shall such information be deemed incorporated by reference in any filing under the Securities Act of 1933, as amended, except as shall be expressly set forth by specific reference in such a filing. The information set forth herein will not be deemed an admission as to the materiality of any information required to be disclosed solely to satisfy the requirements of Regulation FD.

Item 9.01. Financial Statements and Exhibits.

(d) Exhibits

Exhibit 99.1 2012 Analysts Day Presentation Slides

SIGNATURE

Pursuant to the requirements of the Securities Exchange Act of 1934, the Registrant has duly caused this report to be signed on its behalf by the undersigned thereunto duly authorized.

ENTEGRIS, INC.

By /s/ Peter W. Walcott Peter W. Walcott, Senior Vice President & General Counsel

Dated: May 23, 2012

2012 Analyst Day

May 23, 2012



Safe Harbor

Certain information contained in this presentation may constitute forward-looking statements within the meaning of the Private Securities Litigation Reform Act of 1995. These forward-looking statements involve substantial risks and uncertainties that could cause actual results to differ materially from the results expressed in, or implied by, these forward-looking statements. Statements that include such words as "anticipate," "believe," "estimate," "expect," "forecast," "may," "will," "should" or the negative thereof and similar expressions as they relate to Entegris or our management are intended to identify such forward-looking statements. These statements are not guarantees of future performance and involve risks, uncertainties and assumptions that are difficult to predict. These risks include, but are not limited to, fluctuations in the market price of Entegris' stock, Entegris' future operating results, other acquisition and investment opportunities available to Entegris, general business and market conditions and other factors. Additional information concerning these and other risk factors may be found in previous financial press releases issued by Entegris and Entegris' periodic public filings with the Securities and Exchange Commission, including discussions appearing under the headings "Risks Relating to our Business and Industry," "Risks Related to our Borrowings," "Manufacturing Risks," "International Risks," and "Risks Related to Owning Our Securities" in Item 1A of our Annual Report on Form 10–K for the fiscal year ended December 31, 2011, as well as other matters and important factors disclosed previously and from time to time in the filings of Entegris with the U.S. Securities and Exchange Commission. Except as required under the federal securities laws and the rules and regulations of the Securities and Exchange Commission, we undertake no obligation to update publicly any forward-looking statements contained herein.



Agenda

Gideon Argov President and CEO
Bertrand Loy Executive Vice President and COO
lesodd Edlund Vice President and General Manage
CCS Division
Greg Morris
Vice President and General Manage Global Field Operations
Greg Graves
Executive Vice President and CFO
All



The Path to \$1B

Gideon Argov President and CEO



2011: Another Record Year

- We achieved record sales, earnings and cash flow in 2011
- We out-performed our markets
- Strong contribution from new products
- New emerging markets did well, despite challenging environment
- We delivered on our operating model





Proven Strategies in Place to Achieve Superior Growth and Profitability

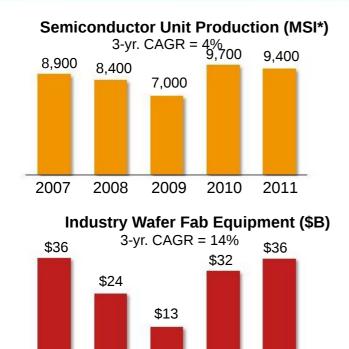


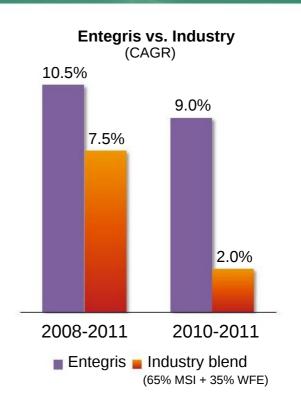
Growth Strategies

- Concentrating on the highest growth fab processes
- Increasing collaboration with technology leaders and largest customers
- Creating and leveraging technology hubs close to critical customers around the world
- Focusing on markets with high growth potential (LED, PV, etc.)
- Targeting our market approach to early technology adopters
- Adapting our core technologies to new markets



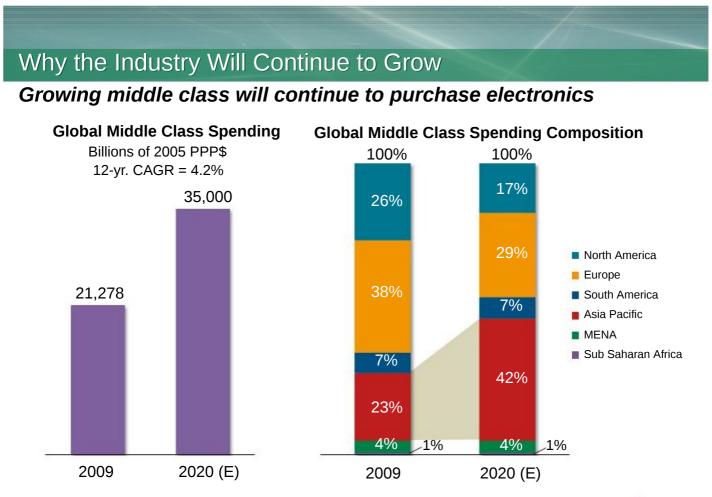
Our Strategy is Working: We're Growing Faster than Our Markets





Source: Gartner, March 2012; Entegris *In millions of square inches of silicon Analyst Day 2012 | 7



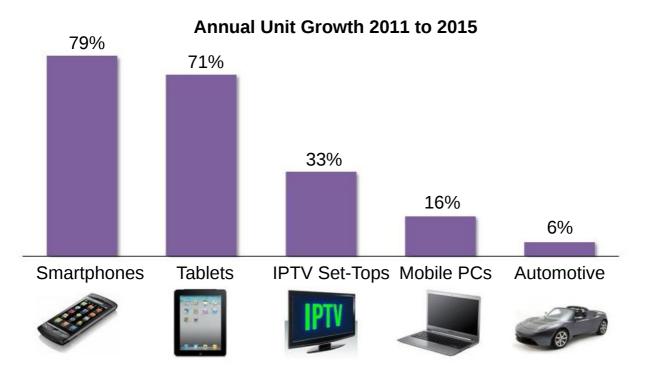


Source: Organization for Economic Cooperation and Development (OECD), 2010 Analyst Day 2012 | 8



Why the Industry Will Continue to Grow

Semiconductor market drivers remain strong



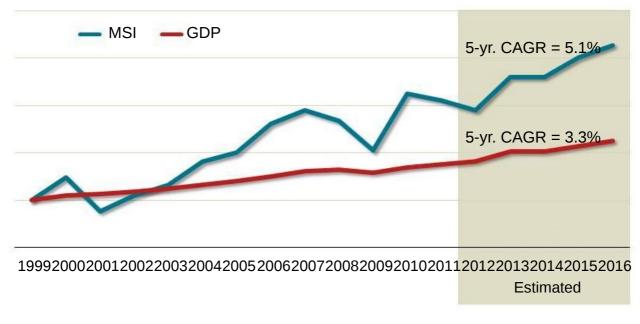
Source: Gartner, December 2011 and March 2012 Analyst Day 2012 | 9





Industry outperforms worldwide GDP

Worldwide Silicon Demand in MSI and Global GDP

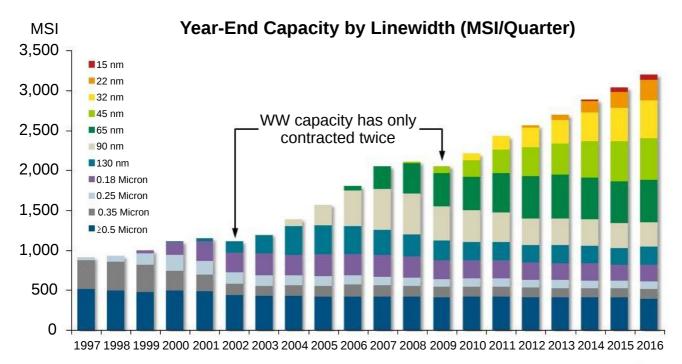


MSI = millions of square inches of silicon Source: Gartner, March 2012



Why the Industry Will Continue to Grow

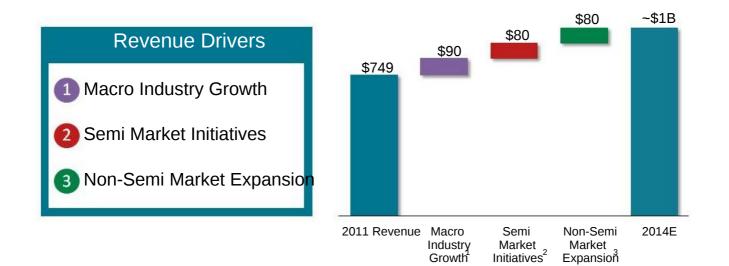
Worldwide capacity increases through advanced technologies; maintains strong base at legacy nodes



Source: Gartner, March 2012



The Path to \$1 Billion



¹ Industry growth less ASP erosion. Based on \$35B annual WFEaBple1216B MSI market size in 2014

- ² Semi Market initiatives in Wet Etch and Clean, Lithography, CMP and 450 mm
- ³ Incremental growth from market share gains in Solar, Life Sciences, LED, LiB, Aerospace, Alt Energy, Consumer Electronics and Optics



When Will We Reach \$1 Billion?

- Need strong industry environment
 - Unit production of 12.6 billion in MSI (5-yr. CAGR = 5.1%)
 - \$35 billion in capital investment
- Continued strong execution
 - New differentiated product solutions
 - Expanding customer relationships
- Growing adjacent markets and acceptance of new solutions



We believe we can achieve a \$1 Billion run rate in 2014 organ



What Makes Entegris Unique

- Importance of what we do in the industry
 - Increasing need for contamination control in advanced manufacturing
 - Entegris is uniquely positioned in the industry
- Fully engaged with the industry market and technology leaders on key technologies including EUV, 3D and 450 mm
- Predominantly recurring, unit-driven business with a long tail of legacy products
- Ability to apply breadth of technology to adjacent areas
- Investing to extend our market and technology leadership and to increase future cash flows



What Node Transitions Mean for Entegris

Bertrand Loy Executive Vice President and COO



Key Points

- We are gaining share due to increased customer focus
- We are expanding the breadth and depth of our technology
- Our "seat at the table's becoming bigger as our customers expect us to do more
- Increasing costs of next generations of technology are creating Darwinian pressure on the entire industry, particularly the supply chain
- We are confident about our long-term opportunities in Semi and in our adjacent markets



Breadth and Depth of Technology

Contamination Control Solutions	2011 Sales	Process Application	Techno	logy	Product Platforms	
	WE	6484 M Lithography, WEC, CMP, Deposition	WEC, CMP, Deposition P		Filtration	Liquid Filters, Gas Filters
				Purification	Gas Purifiers, Purification Systems	
				alytic	Fluid Handling	Valves, Fittings, Sensors, Dispense/Pumps
Microenvironments			and An			
	\$182 M	Wafer and Reticle Handling	Knowledge	Wafer/Reticle Handling	FOUPs, Wafer Shippers, Wafer Carriers, Reticle Pods	
Specialty Materials			ation			
6	\$83 M	lon Implant, Dry Etch	Application	Advanced Materials	Graphite Components, Proprietary Coatings, E-Chucks	

Entegris

Contamination Control Solutions

- Focused on three rapidly growing process areas
 - Wet etch and clean
 - Lithography
 - Chemical mechanical planarization
- \$1.2B served available market
- Largest, rapidly growing, most profitable division



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Products









Dispense/Pumps Fluid Handling



Sensing and Control Containers



Microenvironments

- Carriers and shippers for handling wafers, reticles and other critical substrates
- Investing in advanced process carriers
- \$400M served available market
- Solid cash generator



Products



450 mm HVM MAC



300 mm+ Wafer Handling



300 mm+ Wafer Shipping



Reticle Pods



Specialty Materials

- Focused on high-temperature applications in semiconductor and adjacent markets
- \$300M served available market
- Newest division with diversified opportunities for growth



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Products/Technologies



Premium Graphite and Silicon Carbide

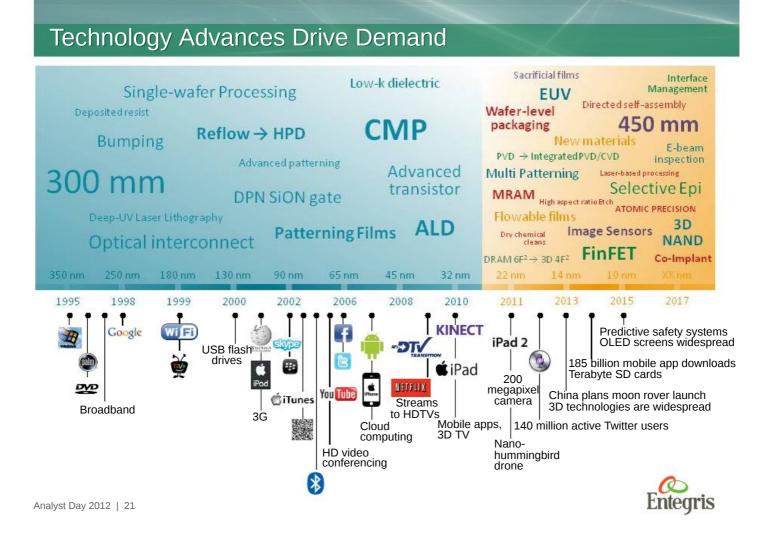


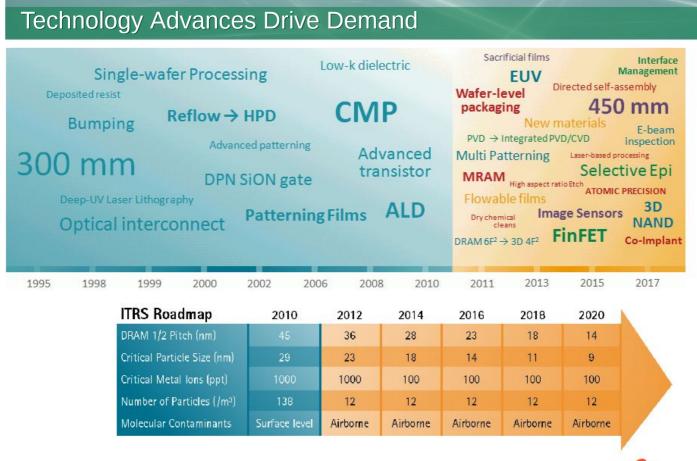


Coatings

E-chucks





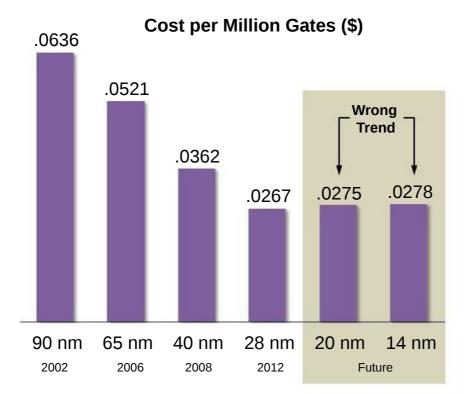


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Entegris

Technological Advancements are Now More Costly

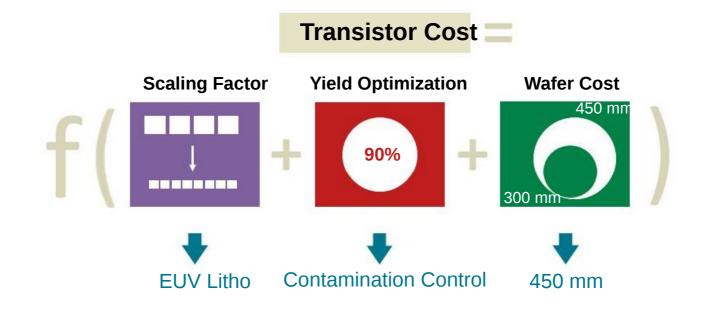
Cost per gate increases at 20 nm



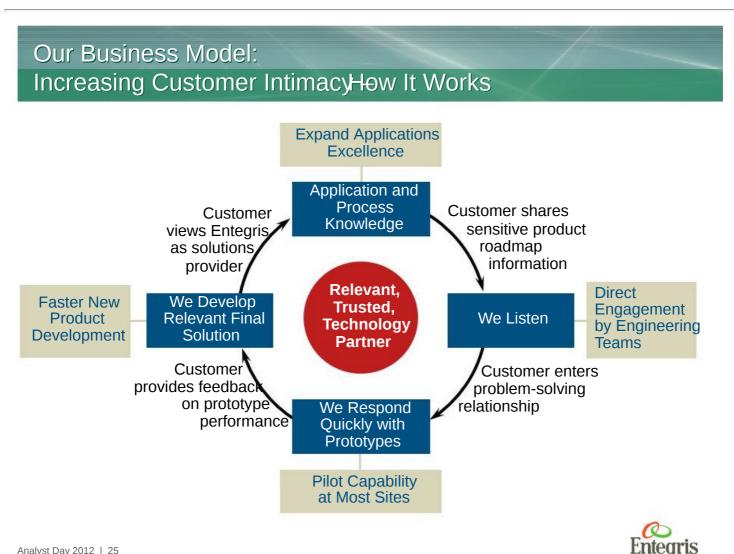
Source: International Business Strategies Inc Analyst Day 2012 | 23

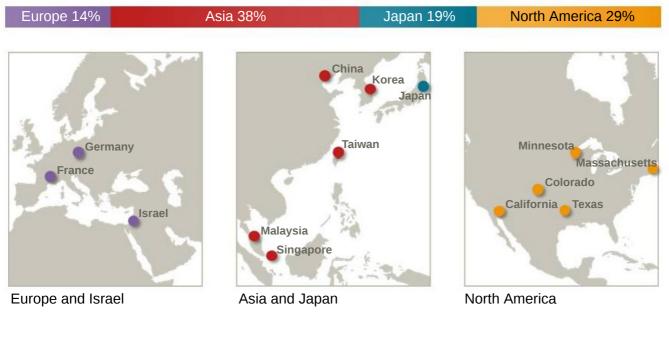


A Massive Technology Shift Ahead









R&D, manufacturing, sales and labs close to customers around the world



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FY11 Sales by Region

Europe



Europe and Israel



COATINGS MANUFACTURING FACILITY Lyon, France





Asia



PURELINE CO., LTD. An Entegris Company Korea





TAIWAN SCIENCE PARK BRANCH Taiwan



North America



i2M CENTER FOR ADVANCED MATERIALS SCIENCE Massachusetts



ADVANCED TECHNOLOGY CENTER Colorado



North America



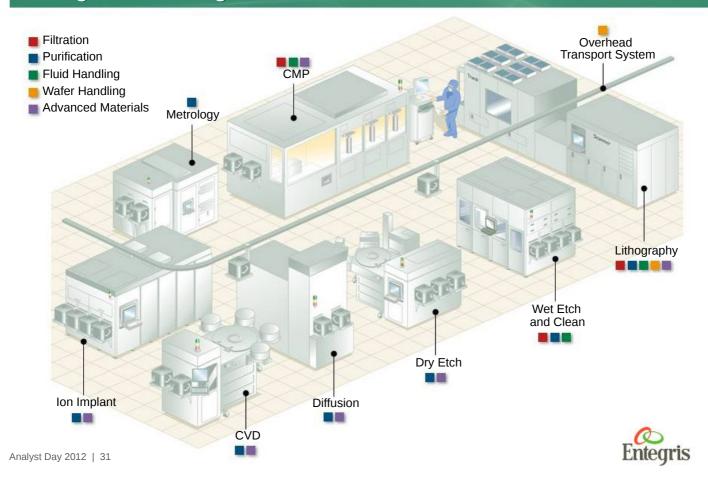
R&D Leveraged to Key Technology Trends

	Key Technology Trends				
Entegris Technologies	EUV	3D	New Materials	450 mm	
Filtration	•		•		
Purification	•	•	•	•	
Fluid Handling			•		
Wafer/Reticle Handling	•	•	•	•	
Advanced Materials/Coatings	•	•	٠	٠	

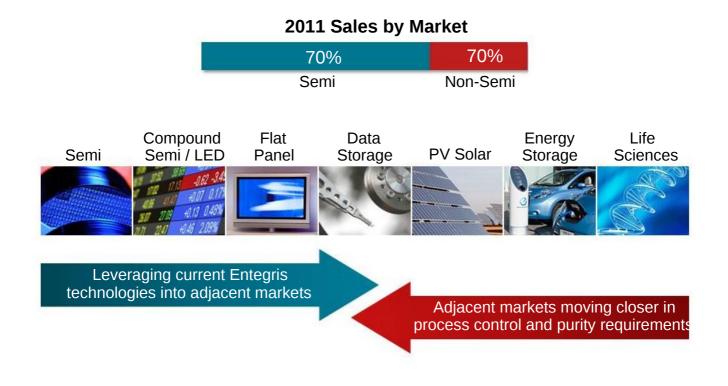
Increasing focus on JDAs and partnerships



Entegris Technologies Touch All Fab Critical Processes



Leveraging Entegris Technologies into Adjacent Markets





A Portfolio of Opportunities in Adjacent Markets





A Portfolio of Opportunities in Adjacent Markets

Comp Semi/LED





Customer Issue

has been shown

to increase yields

in **HBLEDs**

Entegris Solution

Process gas purity Gas purification systems for the MOCVD process







A Portfolio of Opportunities in Adjacent Markets

	Customer Issue	Entegris Solution
Comp Semi/LED	Process gas purity has been shown to increase yields in HBLEDs	Gas purification systems for the MOCVD process
PV Solar	Reducing contaminants in process fluids improves PV cell efficiencies	Gas and liquid filtration combined with ultra-high purity components



A Portfolio of Opportunities in Adjacent Markets

	Customer Issue	Entegris Solution
Comp Semi/LED	Process gas purity has been shown to increase yields in HBLEDs	Gas purification systems for the MOCVD process
PV Solar	Reducing contaminants in process fluids improves PV cell efficiencies	Gas and liquid filtration combined with ultra-high purity components
Aerospace	High temperatures in jet engines require enhanced material performance	Specialized graphite bushings, rings and air seals replace existing materials



Positioned for Growth

- The technology changes facing our industry over the next five years are massive
- Contamination control is becoming even more critical to the industry
- We are working more closely than ever with our customers
- We are investing to fully realize both our near-term and long-term opportunities
- Adjacent markets will recover and will continue to offer paths for growth



Delivering Higher Value at Advanced Nodes

Todd Edlund Vice President and General Manager, CCS Division



Contamination Control Solutions DivisionFocus on Growth

Growth Drivers

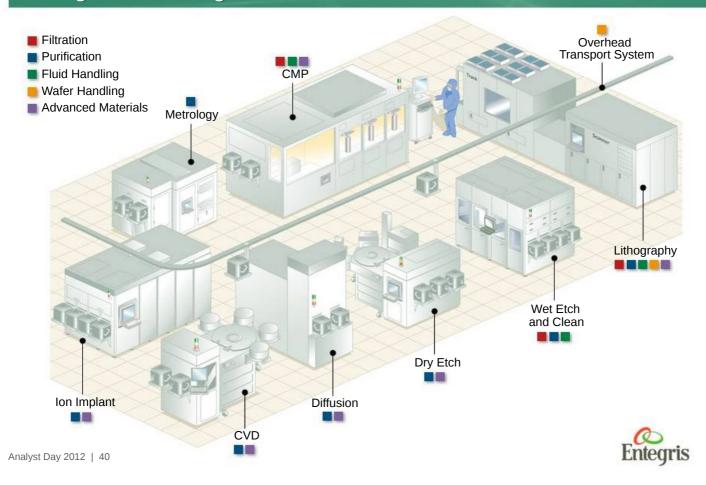
- Bring greater value and additional product solutions to growing semi processes
 - Wet Etch and Clean
 - Lithography
 - □ CMP
- Apply solutions to other challenging markets

CCS is uniquely positioned to control contamination from production of raw chemicals to point of use

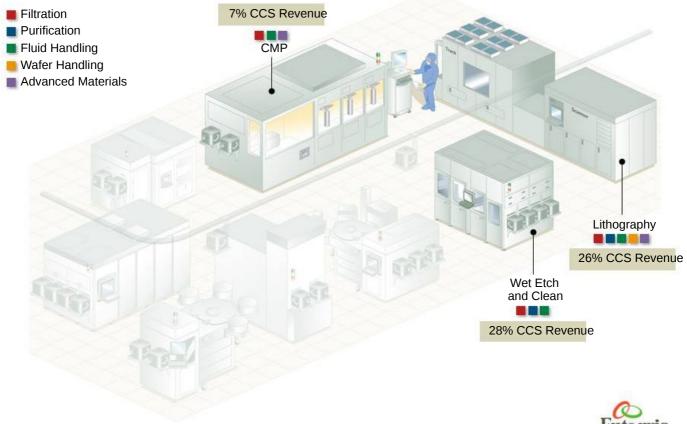




Entegris Technologies Touch All Fab Critical Processes



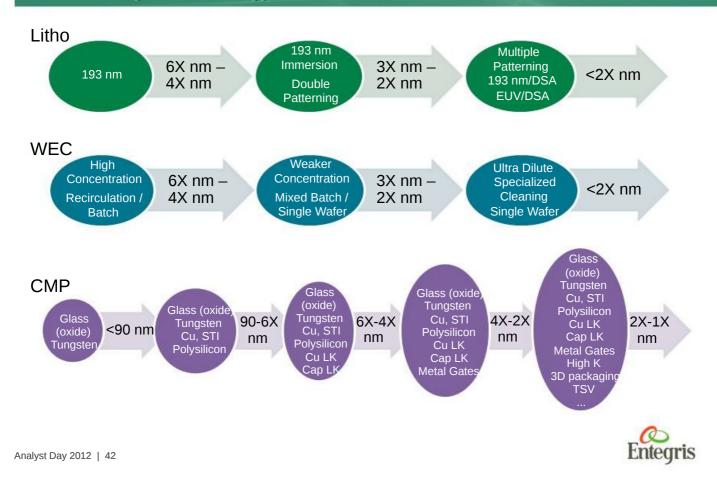
Three Key Process Areas for Entegris



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Entegris

Advancing Technology Nodes Drive Our Product Demands

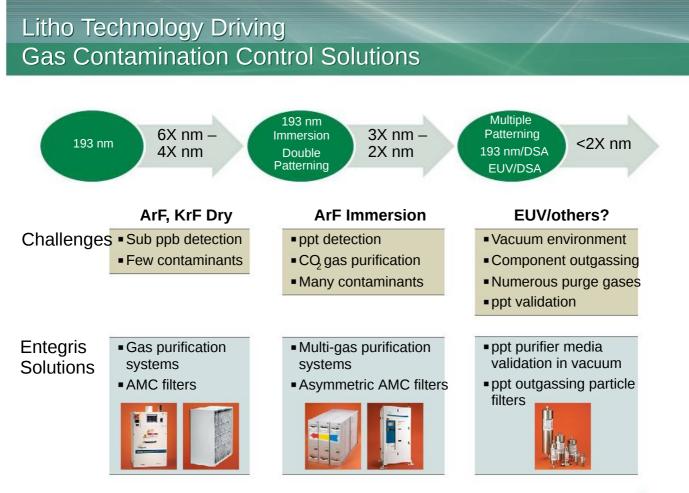


Photolithography Solutions: Blanketing the Process

- Valves
- Fittings
- Pumps
- POU filters
- Gas filters
- Chemical filters
- HUGs
- Reticle pods
- UPW purification systems
- Scanning mirrors



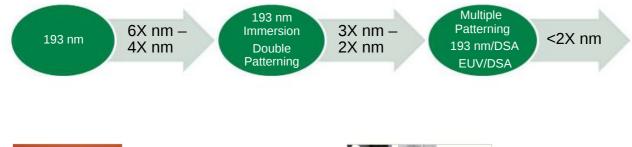




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Entegris

Dispense and Filtration Combination: Increasing Throughput and Yield and Decreasing Waste



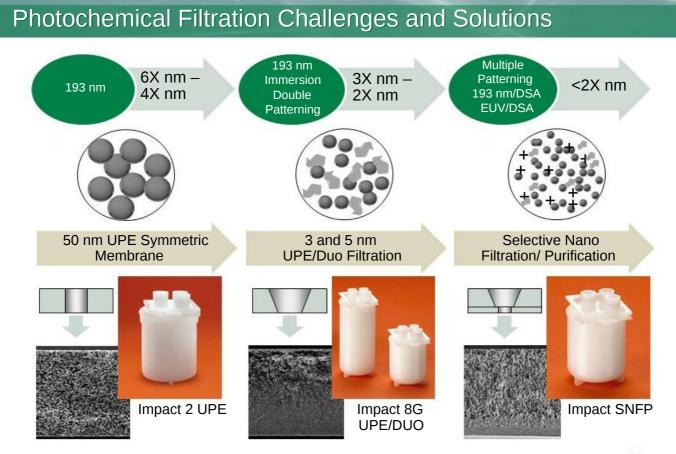


Combining two-stage filtration/dispense and asymmetric filters to reduce microbridging



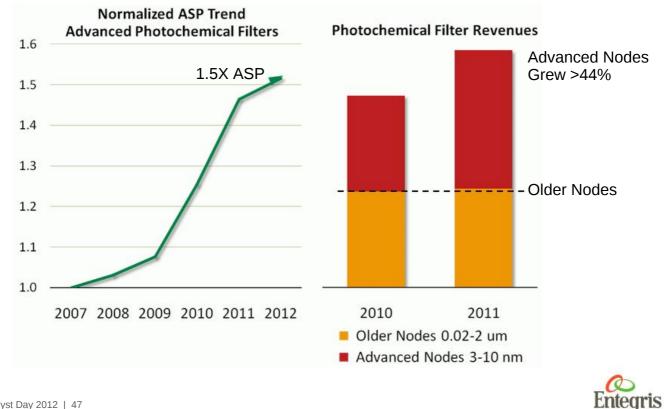
Leveraging RFID smart technology to rapidly eliminate defect-causing microbubbles





Entegris

Photochemical Filtration Delivering Higher Value to Customers



Wet Etch and Clean Solutions: Production to Consumption

- Valves
- Fittings
- Liquid filters
- Flow control
- Containers
- Manifolds



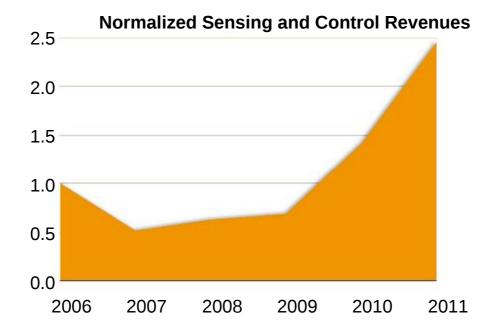




Entegris

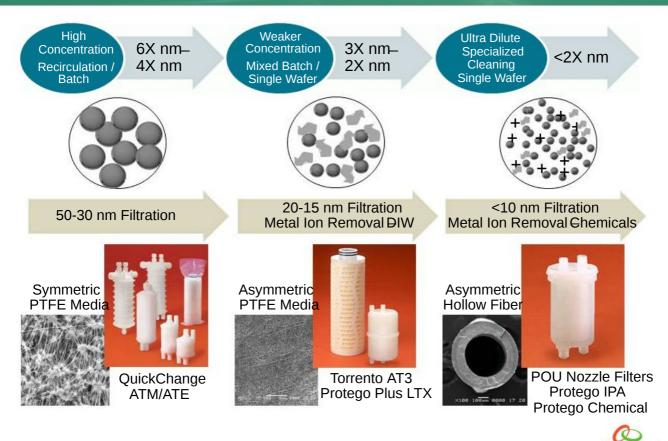
Wet Etch and Clean Revenue: Sensing and Control

Entegris benefits from WEC move to sophisticated flow control



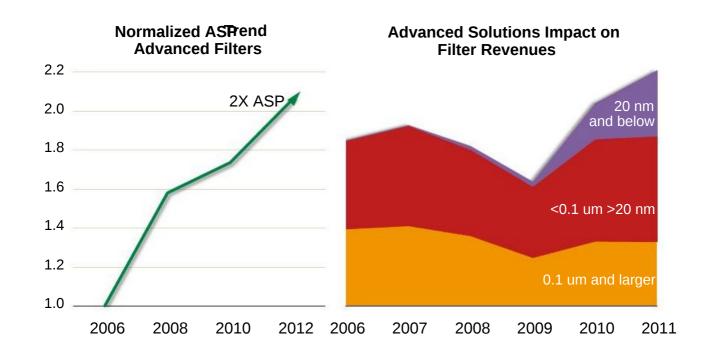






Entegris

WEC Filtration Value Growing with Advanced Technology





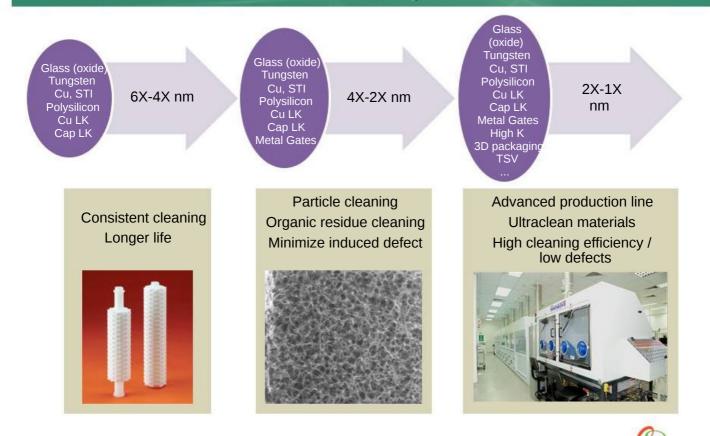
Total CMP Solutions: Room to Grow our SAM

- Filters
- Flow control
- PVA brushes
- Valves
- Fittings
- Containers
- Coatings



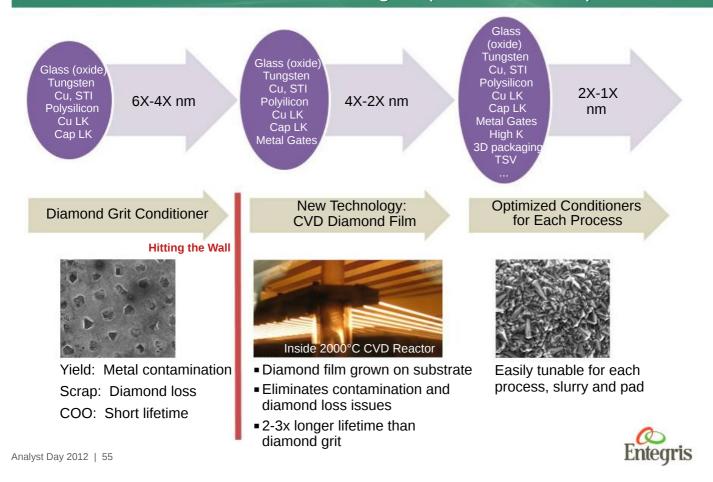


Post CMP Clean Brush: Establishing New SAM

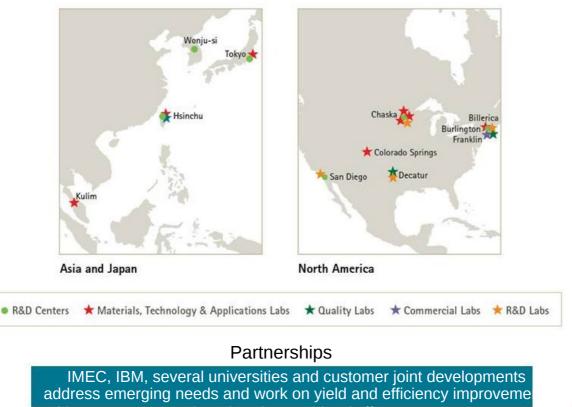


Entegris

CMP Pad Conditioner: Combining Capabilities to Expand our SAM



Entegris R&D Infrastructure Serves Our Diverse Solution Set



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Entegris

The New i2M Center for Advanced Materials Science

- Bedford, MA
- \$55M to \$60M investment
- 100 employees
- Purpose-built for coming generation of nano level capabilities



- Advanced membrane/separation media manufacturing and R&Dliquid and gas applications
- Advanced specialty coating manufacturing and R&D
- New synergistic products
- Commitment to investing in critical capabilities around clean materials and leading-edge contamination control solutions



Advancing Customer Demands Play to Our Strengths

- Challenging contamination control demands at advanced nodes are driving up the value of what we do
- Entegris is already delivering solutions that are being quickly adopted for use in key semiconductor processes
- We're uniquely positioned to deliver comprehensive solutions from material production to consumption
 - Applicable to new market space
- We will make appropriate investments to support the customers that are setting the pace for the industry



Why We Are Winning in the Market

Greg Morris Vice President and General Manager, Global Field Operations



Across the Semiconductor Ecosystem



Only a Handful of Companies Can Afford to Drive Industry Technology Roadmap

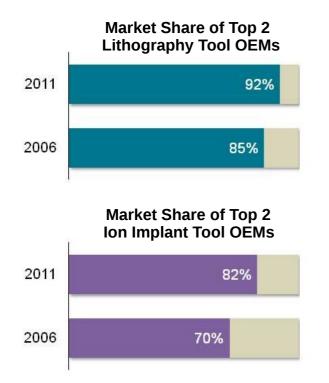
- Fewer fabs can afford cost of next generation
- Top three IDMs (Samsung, Intel and TSMC) control half of total industry spending in 2012
- Top ten control approximately 60% of global capacity
- More logic IDMs go fabless
- More tech partners and joint ventures

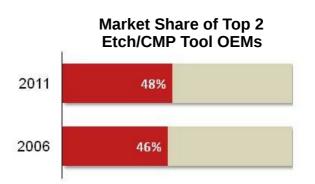
Device makers are managing their technolog roadmaps and supply chains more globally

Source: Gartner, March 2012 Analyst Day 2012 | 61



Our Changing Market Dynamic Consolidation of OEMs





Market Share of Top 2 RTP/Diffusion Tool OEMs



Source: Gartner, March 2012 and April 2007 Analyst Day 2012 | 62



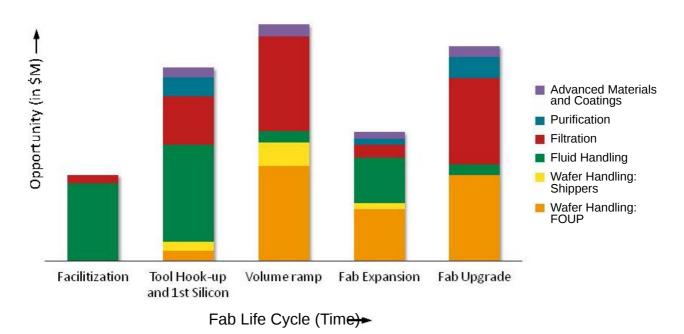
Focusing Our Resources On the Most Strategic and Critical Customers

Tier 3	Tier 2 Tier 1	Strategic and Critical
 Technology 	 Unclear commitment 	 Companies committed
follower	to ITRS	to ITRS
 Migrating to fabless 	 Regional powerhouses 	 Financially strong
 Weaker financial position 	 "Opportunity enablers" 	Market leadersGlobal and complex
 Local 		 Increasingly demanding
Sales Channel Partner	General Sales Force	Dedicated Sales Account Teams
Analyst Day 2012 63		Entegris

Entegris is Leveraged Throughout the Fab Life Cycle

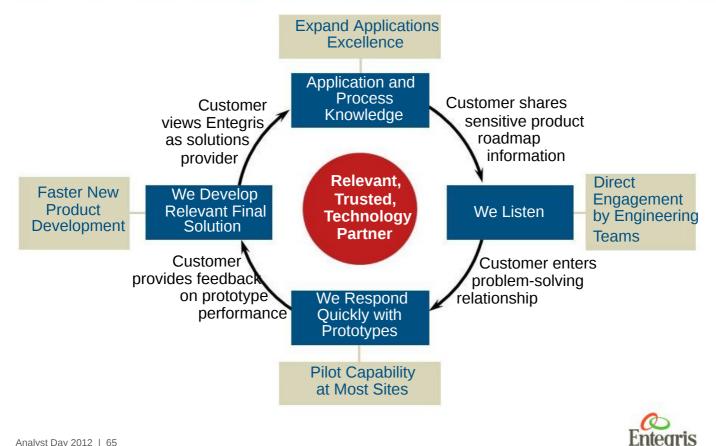
Entegris Sales Opportunity by Product

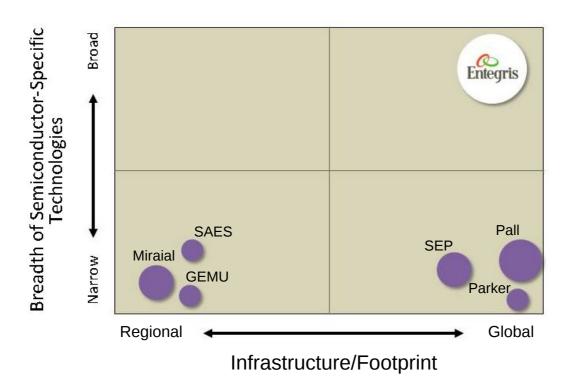
Our solutions have a critical role in volume ramp and fab upgrades





Our Business Model: Increasing Customer Intimacy to Increase Share







Market Share Wins: The Right Technology at the Right Time

Advanced FOUPs at fab customer

- Cross contamination, moisture control and particle reduction at 32 nm created new technical requirements
- We demonstrated our understanding of problem with our ongoing work with OEMs, consortia and technology leaders
- Our investments through the last cycle yielded the right technology at the right time





Market Share Wins: Offering the Most Pure Solutions

Advanced wet etch and clean filtration for fab customers

- Leading fabs consulted with Entegris regarding yield issues occurring during ramp of 32 nm and 28 nm processes
- We quickly delivered our Torrento®filter for wet etch and clean processes
- Torrento uses Entegris' membrane and surface modification expertise to provide the most advanced product on the market for this application





Market Share Wins: Understanding Customer Needs Enables Share Gains in Other Areas

Advanced coatings at OEM customer

- Advanced ion implant processes require chamber components and materials that can withstand high temperature and corrosion
- We used our proprietary coatings technology to develop the market-leading cleaning and coating solution for e-chucks
- Our deep understanding of the OEMstequired technology enabled us to gain share in other advanced materials product areas





Market Share Wins: Offering the Most Pure Solutions

New container solutions for materials customers

- Higher levels of purity of all chemicals is required for 2X technology nodes
- Chemical suppliers require that new container solutions also seamlessly fit with existing fab connections
- Entegris offers the most pure container solutions
- By meeting all country-specific Suppliers transportation standards prior to product launch, Entegris' solutions speed user deployment





In Summary

- Customer consolidation in our markets is providing opportunities to leverage technology and product breadth and global footprint
- We've aligned our field operations to focus on the most impactful customers
- We're winning in the market by increasing our intimacy with key customers



What This Means for Investors

Greg Graves Executive Vice President and CFO



The 2011 Scorecard: Building on Another Great Year



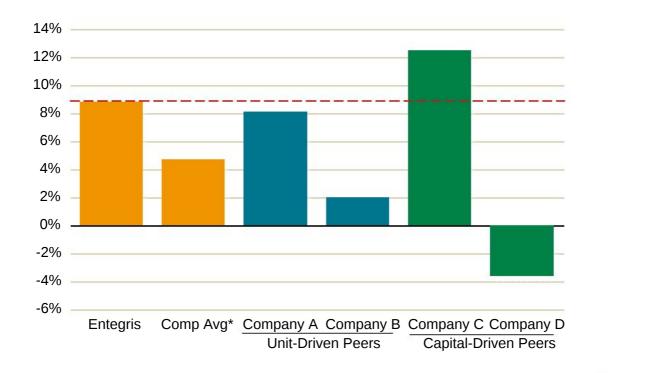
- Record sales of \$749M in 2011
- Grew faster than our markets and our peers
- Record operating profit
- Achieved target model
- Record cash flow from operations
- Cash balance exceeding \$265 million
- Zero debt





Strong Relative Revenue Growth

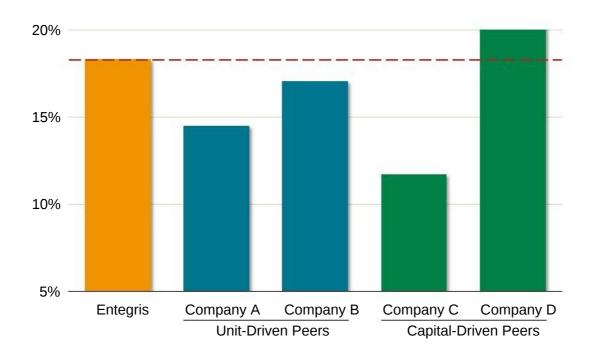
2011 revenue growth vs. peers



*Comparable weighted average growth rate based on 65% unit-driven and 35% capital-driven

Strong Relative Profitability

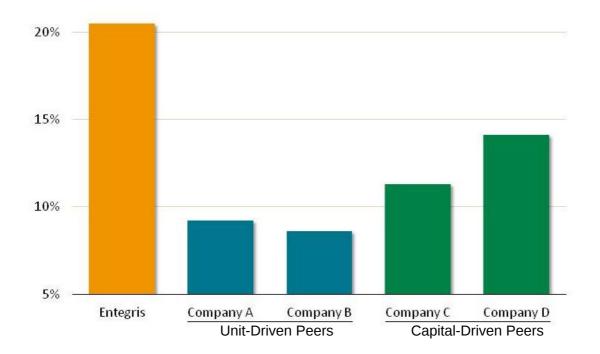
2011 operating margin (EBITA) vs. peers





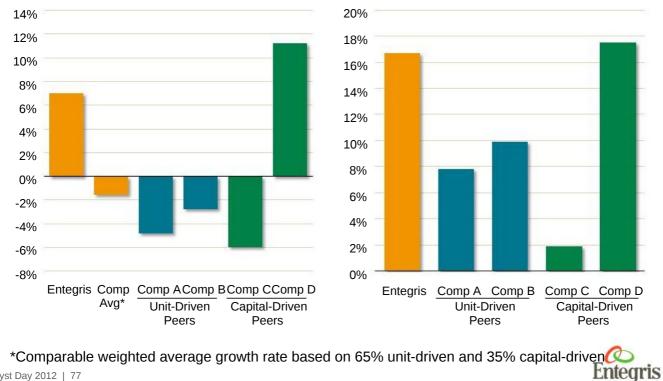
Best-in-Class Return on Invested Capital

2011 ROIC vs. peers





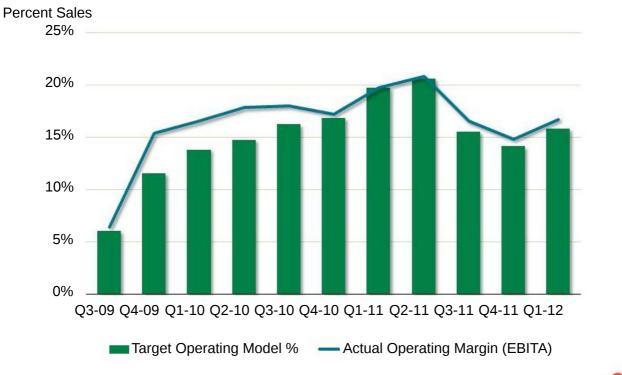
Strong Performance Continues in 2012



Q1-12 Revenue Growth vs. Peers

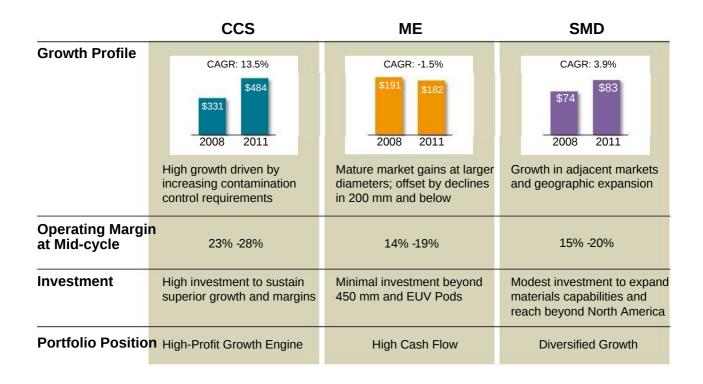
Q1-12 Operating Margin (EBITA) vs. Peers

Achieved Target Model Every Quarter Since Introduction



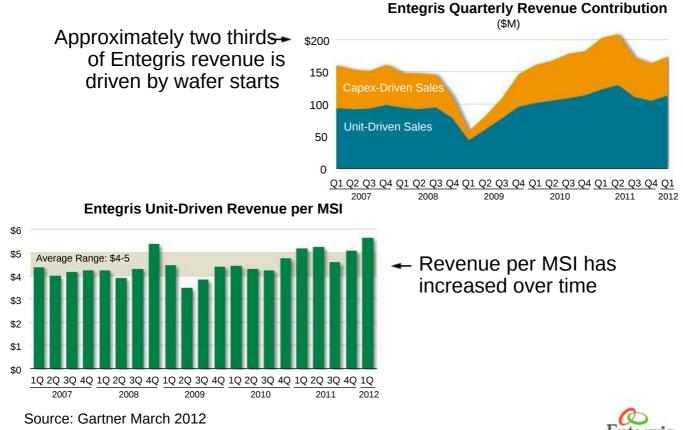


Well Positioned to Continue to Perform: Division Portfolio





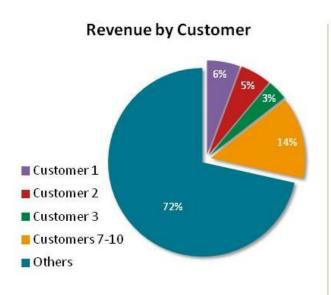
Well Positioned to Continue to Perform: Largely Unit-Driven Business Provides a Stable, Growing Base



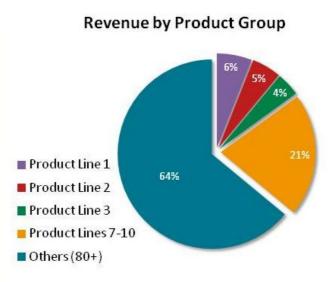
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Entegris

Well Positioned to Continue to Perform: Customer and Product Diversification Contribute to Stability



- Our largest customers are typically only 5% to 7% of total revenue
- Our top ten customers are less than 30% of revenue



- Our largest product lines are typically only 5% to 7% of total revenue
- Our top ten product lines are less than 40% of revenue



Investing to Insure Future Growth

450 300	New Technologies	 Enhancement of 300 mm wafer shipping and process products Market-leading 450 mm solutions Advanced filtration for Wet Etch and Clean
	Enhanced Capabilities	 i2M Center for Advanced Materials Science to support next-generation development of membranes and coatings
Ð	Leveraged Infrastructure	 Sales organization focused on critical customers Labs and specialized manufacturing sites close to key customers



Updated Target Earnings Model at Various Revenue Levels

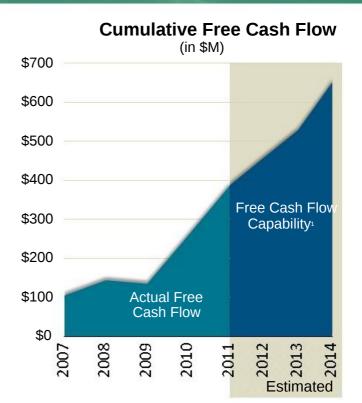
	Q1-08 ¹	Q1-11 ¹	Q1-12 ¹	Quarterly Revenue Level		
Revenue (\$M)	\$148	\$203	\$175	\$170 \$190 \$220		
Adjusted Operating Margin ³	9.4%	19.7%	16.7%	13% -15% 16% -18% 20%+		
Earnings Per Share	\$0.10	\$0.23	\$0.14	\$0.11 -\$0.13 \$0.15 -\$0.17 \$0.22+		

- Goal of \$1 EPS at \$1 billion run rate remains intact
- Increasednvestmentlevelswill be stagedover the next several quarters
- Operating margins are attractive and remain above most comparable companies
- Increased spending at lower revenue levels allows for continued investment through the cycle
- $^1\,$ Q1-08, Q1-11 and Q1-12 results are on a non-GAAP basis.
- ² Represents range of adjusted operating margin based on respective quarterly revenue levels.
- ³ Adjusted operating margin defined as GAAP operating income plus amortization, restructuring costs, impairment of goodwill, and fair value mark-up of inventory.
- Q1-08 shares outstanding equal 116 million. Q1-11 shares outstanding equal 135 million. Q1-12 and all other scenarios shares outstanding equal 138 million.



Strong Cash Flow Across the Cycle

- Generated \$127 million of free cash flow in 2011
- Cumulative free cash flow of \$387 million since 2007
- During the worst downturn in the industry's history, free cash flow was only \$9 million negative
- 2011 EBITDA of \$163 million



 $^1\,\text{Free cash}$ flow capability assumes no M&A activity or change in capital structure $_{\text{Analyst} Day\,2012}$ | $_{84}$



Balance Sheet Continues to Strengthen

\$ and share data in millions

N	March 31, 2012	Dec. 31, 2011	Dec. 31, 2010	Dec. 31, 2009
Cash	\$267	\$274	\$134	\$69
Total Assets	\$736	\$725	\$601	\$505
Total Debt ¹	\$0	\$0	\$0	\$72
ShareholdersEquity	\$628	\$608	\$464	\$350
Common Shares Outstanding	137	136	133	130

At December 2011, Entegris had debt-fre balance sheet and \$2 in cash per share

¹ Total debt equals long-term debt, current maturities of long-term debt, and short-term borrowings



In Summary

- Our results in the past two years demonstrate our ability to out-grow the market and deliver superior profitability and excellent cash flow
- Our core technologies are critical in solving the industry's most difficult contamination issues
- We are expanding the breadth of our technology through sustained and focused investment
- The changes to our target model will provide the flexibility to strategically invest through the semiconductor cycle
- We are committed to continued growth and achieving superior profitability



